Application/Control Number: 10/774,417

Art Unit: 1763

## **CLM-PTO**

## September 28,2004

A method of making a diamond product by etching,
said method comprising the steps of:

forming a diamond substrate with a mask layer; and etching said diamond substrate formed with said mask layer with a plasma of a mixed gas composed of a gas containing an oxygen atom and a gas containing a fluorine atom;

wherein said fluorine tom has a concentration within the range of 0.04% to 6% with respect to the total number of atoms in said mixed gas.

2. A method of making a diamond product according to claim 1, wherein said plasma is produced by generating a high-frequency discharge between two plate electrodes arranged in parallel; and

wherein said high-frequency discharge is generated by supplying an electric power of at least  $0.45~\rm W/cm^2$  between said plate electrodes.

3. A method of making a diamond product according to claim 1, wherein said gas containing said fluorine atom is CF, gas; and

wherein said CF, gas has a concentration within the range of 0.02% to 3% with respect to the total number of molecules in said mixed gas.

4. A method of making a diamond product according to claim 1. Wherein said gas containing said oxygen atom is one of  $C_2$ ,  $CO_2$ , and a mixed gas composed of  $O_2$  and  $CO_2$ .

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## Claims 5-7 are canceled

8. A method of making a diamond product by etching, said method comprising the steps of:

forming a diamond substrate with a mask layer; and etching said diamond substrate formed with said mask layer with a plasma of a mixed gas composed of a gas containing an oxygen atom and a gas containing a balogen atom;

wherein, in an emission spectrum of said mixed gas, an intensity A of an emission peak caused by said oxygen atom and an intensity B of an emission peak caused by oxygen have an intensity ratio A/B which is greater than the intensity ratio A/B obtained from an emission of a plasma which is 100% oxygen.

- 9. A method of making a diamond product according to claim 8, wherein said gas containing said halogen atom is CF, and wherein said mixed gas further contains nitrogen gas.
- 10. A method of making a diamond product according to claim 8, wherein said emission peak caused by said oxygen atomhas a half width of 3 nm or less, and wherein said emission

peak caused by oxygen has a half width greater than 3 nm.